## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

RE Application of:

Chia-Hong Jan

Serial No.:

09/477,870

Art Unit: 2811

Filing Date: January 5, 2000

Examiner: Owen, Douglas W.

For: A DEVICE WITH RECESSED THIN AND

THICK SPACERS FOR IMPROVED

SALICIDE RESISTANCE ON POLYSILICON GATES

**Assistant Commissioner for Patents** 

Washington, D.C. 20231 Attn: Official Draftsperson

## SUBMISSION OF FORMAL DRAWINGS

Dear Sir:

In response to the Notice of Allowability mailed 3/17/2004 enclosed herewith for filing in the above-referenced patent application are 10 sheets of formal drawings, including 57 Figures. The drawing informalities have been noted and the appropriate corrections are incorporated herein.

Respectfully submitted,

BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Date: June 17, 2004

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## FIRST CLASS CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to: ASSISTANT COMMISSIONER FOR PATENTS, WASHINGTON, D.C. 20231 on

June 17, 2004 by: T.J. Delgado.

J. Delgado